



THE UNITED STATES PATENT AND TRADEMARK OFFICE

Patent Application Serial No. 10/816,691
Filing Date April 1, 2004
Inventor Eric R. Blomiley et al.
Assignee Micron Technology, Inc.
Group Art Unit 1763
Examiner Rakesh Kumar Dhingra
Attorney's Docket No. MI22-2510
Customer No. 021567
Title Substrate Susceptor for Receiving a Substrate to be Deposited Upon

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Reference - See Attached Form PTO-1449

In compliance with 37 C.F.R. §§ 1.56, 1.97 and 1.98, your attention is directed to the United States patent listed on the attached Form PTO-1449. No admission is made regarding whether the submitted reference is prior art.

This Supplemental Information Disclosure Statement is being filed before the mailing of a first office action after the filing of a Request for Continued Examination. Therefore, no fee is believed to be required. However, in the event that a fee is required for filing this Supplemental Information Disclosure Statement, please charge the fee specified under 37 C.F.R. § 1.17(p) to Deposit Account No. 23-0925.

Respectfully submitted,

Dated: 3-7-07

By: 
Mark S. Matkin
Reg. No. 32,268

Form PTO-1449		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE			ATTY. DOCKET NO. MI22-2510		SERIAL NO.: 10/816,691		
					APPLICANT: Eric R. Blomiley et al.				
					FILING DATE April 1, 2004		GROUP ART UNIT: 1763		
U.S. PATENT DOCUMENTS									
*Examiner's Initials		Document Number	Date	Name		Class	Subclass	Filing Date If Appropriate	
	AA	5,944,422	08/31/99	Doitel et al.					
	AB								
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FOREIGN PATENT DOCUMENTS									
		Document Number	Date	Country		Class	Subclass	Translation	
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